

United States Patent and Trademark Office

UNITED STATES DEPARTMENT OF COMMERCE United States Patent and Trademark Office Address: COMMISSIONER OF PATENTS AND TRADEMARKS Washington, D.C. 20231 www.uspto.gov

APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO
10/036,955	12/20/2001	Satoru Mayuzumi	NEC 01FN061	4588
75	590 08/14/2002			
Norman P. Soloway HAYES, SOLOWAY, HENNESSEY, GROSSMAN & HAGE, P.C.			EXAMINER	
			IM, JUNGHWA M	
175 Canal Street Manchester, NH 03101			ART UNIT	PAPER NUMBER
Wallellester, IVI	1 03101		2811	
			DATE MAILED: 08/14/2002	

Please find below and/or attached an Office communication concerning this application or proceeding.

		Application No.	Applicant(s)			
		10/036,955 MAYUZUMI, SATORU				
	Office Action Summary	Examiner	Art Unit			
		Junghwa M. Im	2811			
Peri d fo	The MAILING DATE of this communication app r Reply	1 -				
THE N - Extennafter S - If the - If NO - Failum - Any re	ORTENED STATUTORY PERIOD FOR REPLY MAILING DATE OF THIS COMMUNICATION. Issions of time may be available under the provisions of 37 CFR 1.13 SIX (6) MONTHS from the mailing date of this communication. period for reply specified above is less than thirty (30) days, a reply period for reply is specified above, the maximum statutory period we to reply within the set or extended period for reply will, by statute, eply received by the Office later than three months after the mailing dipatent term adjustment. See 37 CFR 1.704(b).	36(a). In no event, however, may a reply be t y within the statutory minimum of thirty (30) da vill apply and will expire SIX (6) MONTHS fror , cause the application to become ABANDON	imely filed ays will be considered timely. In the mailing date of this communication. ED (35 U.S.C. § 133).			
1)⊠	Responsive to communication(s) filed on 12 J	<u>lune 2002</u> .				
2a)□	This action is FINAL . 2b)⊠ Th	is action is non-final.				
3) Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under <i>Ex parte Quayle</i> , 1935 C.D. 11, 453 O.G. 213. Disposition of Claims						
4) Claim(s) 1-20 is/are pending in the application.						
4a) Of the above claim(s) 17-20 is/are withdrawn from consideration.						
5)	5) Claim(s) is/are allowed.					
6)⊠	⊠ Claim(s) <u>1-16</u> is/are rejected.					
7)	Claim(s) is/are objected to.					
•	Claim(s) are subject to restriction and/or on Papers	r election requirement.				
· ·	The specification is objected to by the Examine	r.				
· —	Fhe drawing(s) filed on is/are: a)□ accep		aminer.			
. •, 🗀 .	-					
Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a). 11) The proposed drawing correction filed on is: a) approved b) disapproved by the Examiner.						
,_	If approved, corrected drawings are required in rep		·			
12)∏ T	Fhe oath or declaration is objected to by the Ex					
<i>,</i> —	nder 35 U.S.C. §§ 119 and 120					
•	• •	priority under 35 U.S.C. § 1190	a)-(d) or (f).			
13)⊠ Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f). a)⊠ All b)□ Some * c)□ None of:						
,-	1. ☐ Certified copies of the priority documents have been received.					
	Certified copies of the priority documents have been received in Application No					
	Copies of the certified copies of the prior application from the International Buree the attached detailed Office action for a list.	rity documents have been receiv reau (PCT Rule 17.2(a)).	ved in this National Stage			
	cknowledgment is made of a claim for domestic					
•	☐ The translation of the foreign language pro					
15)∏ A	scknowledgment is made of a claim for domesti					
Attachment	• •		(DTO 440) D			
2) Notice	e of References Cited (PTO-892) e of Draftsperson's Patent Drawing Review (PTO-948) nation Disclosure Statement(s) (PTO-1449) Paper No(s) <u>3</u>	5) Notice of Informal	ry (PTO-413) Paper No(s) Patent Application (PTO-152)			
S. Patent and Tra		tion Summary	Part of Paper No. 6			

Art Unit: 2811

DETAILED ACTION

Election/Restrictions

Applicant's election without traverse of claims 1-16 in Paper No. 5 is acknowledged.

Claim Rejections - 35 USC § 112

Claims 11-13 are rejected under 35 U.S.C. 112, second paragraph, as being indefinite for failing to particularly point out and distinctly claim the subject matter which applicant regards as the invention.

In each of these claims, "said side walls" has unclear antecedent, because claims 1, 2, and 3 recite "a side wall," which is singular, and "said side walls" is plural.

Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

Claims 1, 3-4, 6, 11, 13-14, and 16 are rejected under 35 U.S.C. 103(a) as being unpatentable over Gardner et al.

With respect to claim 1, figure 3E of Gardner et al. shows a device comprising substrate 100, gate insulation film 302, and gate electrode 304, having a portion increasing in length in the upward direction. 306, 308 form a side wall, formed on a side

Art Unit: 2811

surface of the gate electrode, that is covered behind a top part of the gate electrode as seen from above. (If "formed on a side surface of said gate electrode" is construed narrowly to mean "touching" the gate electrode, then the portion of layer 302 that does not lie between the gate electrode and the channel region can be included as part of the "side wall." See also figure 2C, where side wall 204 touches gate electrode 202.) An interlayer insulation film covering the gate electrode and contacting the side wall would have been obvious as shown by insulator 508 in figure 5, in order to support upper layers including a gate contact electrode 512, which is necessary for a functioning device.

With respect to claim 3, side wall 306, 308 is a lamination of oxide and nitride (column 6, lines 33-42), which have different "etching properties."

With respect to claims 4 and 6, the gate electrode 304 has a lower part of constant length, and an upper part that increases in length in the upward direction.

With respect to claims 11 and 13, each of the side walls has an upper part 306 of oxide formed on a side surface of the upper part of the gate electrode, and a lower part 308 of nitride, formed on a side surface of the lower part of the gate electrode.

With respect to claims 14 and 16, the side surface of the upper part of gate electrode 304 is tapered.

Claims 7 and 9 are rejected under 35 U.S.C. 103(a) as being unpatentable over Gardner et al. as applied to claims 1, 3-4, 6, 11, 13-14, and 16 above, and further in view of Satoh et al.

Art Unit: 2811

Figure 4C and 4E of Satoh et al. show gate electrode shapes that have a "visor part," or a part overhanging the lower part of the gate electrode with substantially constant length. The purpose of the gate electrode shapes taught in this reference is to diminish capacitance (see the paragraph spanning columns 4 and 5) and to aid in forming LDD extensions for source and drain (figures 8A-8C). It would have been obvious to adopt the gate electrode shapes taught by Satoh et al. in fashioning the Gardner device for either of these reasons.

Claims 2, 5, 10, 12 and 15 are rejected under 35 U.S.C. 103(a) as being unpatentable over Gardner et al. as applied to claims 1, 3-4, 6, 11, 13-14, and 16 above, and further in view of Kim.

With respect to claims 2 and 10, the cover figure of Kim shows contact 60b, extending from gate electrode 30b1 to drain region 40b, and contacting the vertical side wall of the gate electrode. It would have been obvious to include a similar contact in the Gardner device, in order to implement an SRAM cell having this particular circuit connection of gate shorted to drain, as discussed at Kim column 4, lines 28-37.

With respect to claim 5, the Gardner gate electrode 304 has a lower part of constant length, and an upper part that increases in length in the upward direction.

With respect to claim 12, each of the Gardner side walls has an upper part 306 of oxide, and a lower part 308 of nitride, as noted above.

With respect to claim 15, the side surface of the upper part of the Gardner gate electrode 304 is tapered.

Art Unit: 2811

Page 5

Claim 8 is rejected under 35 U.S.C. 103(a) as being unpatentable over Gardner

and Kim as applied to claim 1-6 and 11-16 above, and further in view of Satoh et al.

As noted above with respect to claims 7 and 9, Figures 4C and 4E of Satoh et al.

teach the "visor" overhang for a gate electrode, which would have been obvious to

diminish parasitic capacitance and to aid in formation of LDD regions, as taught by

Satoh et al.

Conclusion

Any inquiry concerning this communication or earlier communications from the

examiner should be directed to Junghwa M. Im whose telephone number is (703) 305-

3998. The examiner can normally be reached on MON.-FRI. 8:30AM-5:00PM.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's

supervisor, Tom Thomas can be reached on (703) 308-2772. The fax phone numbers

for TC 2800 are (703) 308-7722 (regular communications) and (703) 308-7724 (After

Final communications).

Sara Crane

Primary Examiner